



The Compact Muon Solenoid Experiment

Conference Report

Mailing address: CMS CERN, CH-1211 GENEVA 23, Switzerland



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3D silicon pixel sensors for the CMS experiment tracker upgrade

Davide Zuolo on behalf of the Tracker Group of the CMS Collaboration

Abstract

The upgrade program of the CMS experiment in view of the LHC High Luminosity phase (HL-LHC) includes a replacement of the silicon pixel tracker. This is necessary to guarantee the same tracking performance of the current detector under harsher operating conditions, including higher radiation fluences and hit rates. The first layer of the central (barrel) detector will be located at radial distance of 3 cm from the interaction point where the radiation fluence after 7 years of operation will be $1.9 \times 10^{16} \text{ n}_{eq}/\text{cm}^2$. Following an extensive R and D program, comprising both laboratory and test beam measurements, 3D sensors will be employed in this layer due to their higher radiation tolerance and lower power consumption after irradiation. The final design of the sensors will be presented, together with the most recent laboratory measurements. The main focus will be on the most recent test beam measurements, before and after irradiation up to $1.5 \times 10^{16} \text{ n}_{eq}/\text{cm}^2$, that proved a hit detection efficiency larger than 96% at normal incidence with less than 2% masked pixels, for applied bias voltages larger than 120 V.

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3D silicon pixel sensors for the CMS experiment tracker upgrade

Davide Zuolo^{a,1,*}

^aUniversity of Colorado – Boulder, Boulder (CO), United States

Abstract

The upgrade program of the CMS experiment [1] in view of the LHC High Luminosity phase (HL–LHC) includes a replacement of the silicon pixel tracker. This is necessary to guarantee the same tracking performance of the current detector under harsher operating conditions, including higher radiation fluences and hit rates. The first layer of the central (barrel) detector will be located at radial distance of 3 cm from the interaction point where the radiation fluence after 7 years of operation will be $1.9 \times 10^{16} n_{eq}/cm^2$. Following an extensive R&D program, comprising both laboratory and test beam measurements, 3D sensors will be employed in this layer due to their higher radiation tolerance and lower power consumption after irradiation. Test beam measurements after irradiation up to $1.6 \times 10^{16} n_{eq}/cm^2$ showed a hit detection efficiency larger than 96% at normal incidence with less than 2% masked pixels, for applied bias voltages between 100 V and 130 V.

Keywords: 3D Pixel, Silicon, Sensors, CMS experiment, High-Luminosity LHC, Radiation hardness.

1. Introduction

The High Luminosity upgrade of the Large Hadron Collider at CERN (HL–LHC) calls for an upgrade of the Compact Muon Solenoid (CMS) experiment to operate with higher instantaneous luminosities (up to $7.5 \times 10^{34} cm^{-2}s^{-1}$) and number of collisions per bunch crossings (up to 200). The innermost section of the CMS Tracker detector, composed by hybrid silicon pixel modules, will be entirely replaced [2]. The upgraded CMS Inner Tracker (IT) extends the tracking coverage up to pseudorapidity $|\eta| = 4.0$, optimizes the layer arrangement, and improves the pixel granularity by a factor of six. It consists of three substructures: the Tracker Barrel Pixel (TBPX) with four layers, the Tracker Forward Pixel (TFPX) with eight small double-discs per side, and the Tracker Endcap Pixel (TEPX) with four additional large double-discs per side. Planar n–in–p sensors will be employed in the three sections but the innermost layer of TBPX, which will be located at a radial distance of 3 cm from the interaction point. At such distance the irradiation fluence after 7 years of operation will be $1.9 \times 10^{16} n_{eq}/cm^2$. Following an extensive R&D program involving Fondazione Bruno Kessler (FBK, Italy) and Centro Nacional de Microelectrónica (CNM,

Spain), comprising both laboratory and test beam measurements, 3D sensors will be employed in this layer due to their higher radiation tolerance and lower power consumption after irradiation. 3D pixel sensors have columnar electrodes penetrating the bulk perpendicular to the sensor surface as can be seen in Figure 1. Unlike in planar sensors, the inter-electrode distance is decoupled from the device active thickness opening the possibility to a large reduction of charge trapping after irradiation. For both planar and 3D sensors the pixel cell dimensions will be $25 \times 100 \times 150 \mu m^3$. A production contract with FBK has been signed at the beginning of 2023 and the first sensor wafers are expected by July 2024.

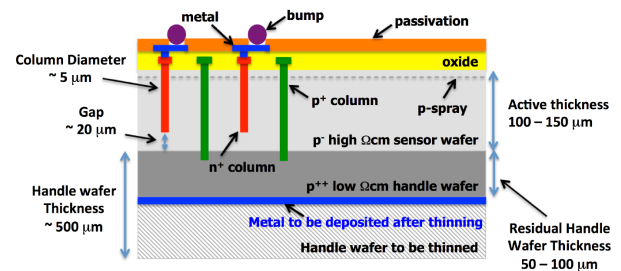


Figure 1: Cross-section of a typical FBK 3D silicon pixel sensor, showing the high resistivity (HR) and low resistivity (LR) layers, together with the p^+ ohmic columns and the n^+ junction columns.

*Corresponding author

Email address: davide.zuolo@cern.ch (Davide Zuolo)

¹On behalf of the Tracker Group of the CMS Collaboration

34 2. Test Beam results

35 Test beam characterization of single chip assemblies composed 69
 36 by a sensor bump bonded to the CROCv1 readout chip 70
 37 (ROC) developed by the RD53 collaboration have been carried 71
 38 out at the CERN SPS (120 GeV pions), Fermilab FTBF (120 72
 39 GeV protons) and DESY (5.2 GeV electrons) facilities during 73
 40 2022 and 2023. Unirradiated samples showed a detection effi- 74
 41 ciency at normal incidence larger than 98% already at 5 V bias 75
 42 voltage, compatible with the columns inactive area. Efficiencies 76
 43 larger than 99.5% are achieved once the modules are tilted 77
 44 by few degrees. The same angular scan allows measurement 78
 45 of the hit position resolution which is found to be as low as 2 79
 46 μm . Several assemblies have been irradiated at the CERN PS 80
 47 (24 GeV protons) and KIT (25 MeV protons). Hit detection 81
 48 efficiencies larger than 96% at normal incidence with less than 82
 49 2% masked pixels can be achieved with sensors irradiated at 83
 50 $1.6 \times 10^{16} \text{ n}_{\text{eq}}/\text{cm}^2$ for applied bias voltages between 100 V and
 51 130 V as can be seen in Figure 2.

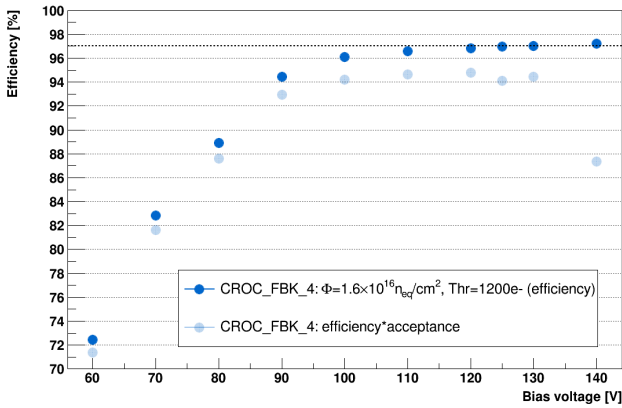


Figure 2: Hit detection efficiency as a function of the applied bias voltage for a single chip assembly irradiated at $1.6 \times 10^{16} \text{ n}_{\text{eq}}/\text{cm}^2$. The light color points represents the product of efficiency and acceptance, defined as $1 - \frac{N_{\text{masked}}}{N_{\text{total}}}$ where N_{masked} is the number of masked pixels and N_{total} is total number of pixels in the sensor.

52 3. Bump bonding

53 Detector modules of TBPX Layer 1 will be composed of two 88
 54 3D sensors bump bonded to two ROCs. Few test modules have 89
 55 already been assembled and the bump bonding quality has been 90
 56 assessed using two different methodologies. The first consists 91
 57 in exposing the module to X-rays or beta sources for a time 92
 58 long enough to guarantee uniform absorption and identify the 93
 59 pixels that do not register hits. In order to reduce the duration of 94
 60 the test a new methodology, based on the study of pixel thresh- 95
 61 old and noise, has been adopted. The module is first supplied 96
 62 the typical reverse bias voltage (i.e. -20 V) and then a small 97
 63 direct bias voltage ($+0.5 \text{ V}$) is applied. The ROCs are cali- 98
 64 brated to an average threshold of 6000 electrons and per-pixel
 65 threshold and noise are measured with both voltages: pixels
 66 connected to damaged bumps are expected to see no changes in
 67 their values.

68 4. Serial powering

Power distribution in the current tracker detector of CMS is based on DC–DC converters. Such a powering scheme cannot be applied to the new IT because the number of DC–DC converters required to power a significantly larger number of channels would impact severely the material budget of the detector. Furthermore, such devices are not sufficiently radiation hard to be deployed in every section of the detector. Detector modules of the Inner Tracker, composed by a single sensor bump bonded to 2 or 4 ROCs, will be connected in serial powering chains composed by up to 11 modules. Shunt-LDO (Low DropOut) regulators [3] on every ROC will ensure that the correct bias voltage is supplied to the analog and digital domains of the chip and will provide shunt functionality for excess currents not consumed by the chip. An example of V–I curve of a ROC belonging to a serial powering chain is shown in Figure 3.

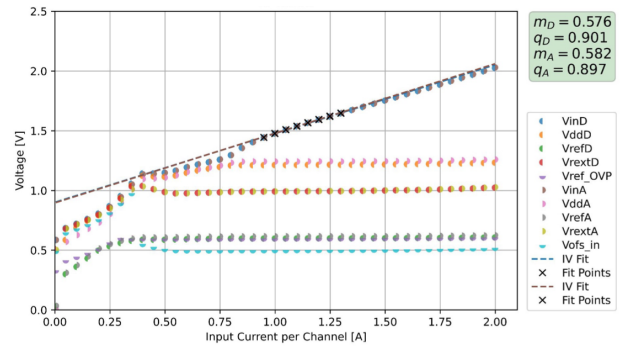


Figure 3: V–I curve of the ROC bonded to a 3D sensor belonging to a chain of 10 modules. The curve shows the ROC is working in an ohmic regime as expected and that the digital and analog voltages remain constants once the operation point of 1.2 V is reached.

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88 References

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